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(54) MANUFACTURE OF QUARTZ GLASS

(57)Abstract:

PURPOSE: To obtain quartz glass free from cracking and easy to dehydrate by cooling and freezing silicic acid gel formed by the hydrolysis of a silicon compound after which the gel is vacuum dried and converted into transparent glass by heat dehydration.

CONSTITUTION: A hydrolyzable silicon compound is hydrolyzed in a liq. phase to form silicic acid gel. This gel is then cooled, freezed, vacuum dried, and converted into transparent glass by heating in an atmosphere contg. a halogen-contg. dehydrating agent. The silicon compound used includes alcoholates such as Si(OCH₃)₄ and Si(OC₂H₅)₄ represented by formula Si(OR)₄ (where R is alkyl) and SiCl₄. The dehydrating agent is added to remove OH groups in porous gel or quartz glass, and SOCl₂, SO₂Cl₂, S₂Cl₂, CCl₄ or the like is used as the agent.

LEGAL STATUS

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